

Authors

Etienne Gorog

IBM Corporate Headquarters, Armonk, New York

B.S., 1952-53, University of Paris; Lic. es-Sci., 1957, University of Paris and Rennes; Ph.D. in Applied Mathematics, 1961, Faculté des Sciences, Grenoble. Joined IBM World Trade Corporation in 1960 at the French Laboratory and was engaged in research on applications of modern algebra to coding and switching theory. From 1963 until 1965 he worked on advanced modern technology and in 1965 was given corporate technological responsibility for modern development. Since December 1965, he has been technical advisor to the Vice President-Chief Scientist of IBM.

John D. Gould

Thomas J. Watson Research Center, Yorktown Heights, New York

B.A. in English, 1959, St. Mary's College, Winona, Minnesota; M.S., 1961; and Ph.D. in Experimental Psychology, 1963, University of Wisconsin. Joined IBM Research in 1963 and has worked on problems of human visual perception and visual displays. Member, American Psychological Association, Eastern Psychological Association, Midwestern Psychological Association, Psychonomic Society, and American Association for the Advancement of Science.

Ivan Haller

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in Chemical Engineering, University of Technical Sciences, Budapest, 1956; Ph.D. in Chemistry, University of California, Berkeley, 1961. Texaco Fellow in Chemistry, 1959-60. Joined IBM Research in 1960 where he has been engaged in the fields of matrix isolation studies, spectroscopy, photochemistry, electron bombardment induced reactions, thin films, and photoresists. Member American Chemical Society, American Physical Society, Phi Beta Kappa, and Sigma Xi.

M. Hatzakis

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in Electrical Engineering, 1964, New York University; has completed work for M.S. in E.E. at N. Y. U. Joined IBM at the Research Center in 1961, working in the electron beam group. Participated in development of the electron beam recorder for a photographic storage project, and in the large-scale circuit integration program. Presently working on the development of microfabrication techniques using electron beams. Member, Tau Beta Pi and Eta Kappa Nu.

David P. Kennedy

Components Division, East Fishkill, New York

Member of Radiation Laboratory, MIT, 1940-42, engaged in the design of radar equipment. From 1942-58 was employed by Raytheon Manufacturing Company to work in the fields of microwave tubes, microwave communication systems, and semiconductor devices. Instructed at the Graduate School of Engineering, Northeastern University, 1953-58. Joined the IBM Development Laboratory, Data Systems Division, Poughkeepsie, in 1958 as an Advisory Physicist in the mathematical analysis of boundary value problems relating to the design and development of semiconductor devices. Is currently a Senior Physicist and Manager of Mathematical Analysis, Semiconductor Device Theory at the East Fishkill laboratory. Member, American Physical Society.

Karl L. Konnerth

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in E.E., Carnegie Institute of Technology, 1954; M.S. in 1955 from Carnegie; and Ph.D. in E.E. in 1961 from Carnegie. Assistant professor of Electrical Engineering at Carnegie Institute of Technology from 1961-64. Joined IBM as a staff research engineer at the Thomas J. Watson Research Center in 1964. Presently engaged in studies of injection lasers and electroluminescence. Member, IEEE.

A. Douglas McLean

Research Division, San Jose, California

B.S. in Chemistry, University of Western Australia, 1950; Ph.D. in Chemistry, University of Chicago, 1967. Worked in R. S. Mulliken's laboratory under C. C. J. Roothaan, 1952-1959. Senior lecturer, University of Western Australia, 1960-1962. Joined IBM in 1962 and is currently assigned to the Large Scale Scientific Computation Department in the San Jose Research Laboratory. Responsible for the development of general purpose computer programs for research on molecular structures and properties.

Walter Makous

University of Washington, Seattle, Washington

B.A., 1958, University of Wisconsin; M.A., 1961; and Ph.D., 1964, Brown University, all in Psychology. From 1963 to 1966 he was on the research staff at IBM's Thomas J. Watson Research Center in Yorktown Heights, after which he joined the faculty in the Psychology Department at the University of Washington, in Seattle. His current research is on the physiological mechanisms of light and dark adaption in a wide variety of photoreceptive organs. He was a National Science Foundation Research Fellow as a graduate student, and is a member of Sigma Xi, Phi Beta Kappa, American Psychological Association, and the Optical Society of America.

John C. Marinace

Thomas J. Watson Research Center, Yorktown Heights, New York

B.S. in Physics, 1959, University of Denver. Joined the General Electric Company, Schenectady, in 1959. Continued working in the semiconductor field after joining IBM Research Laboratory at Poughkeepsie in 1956. Since 1962 has been engaged in injection laser research. Member of Sigma Pi Sigma and the American Physical Society.

Philip C. Murley

Components Division, East Fishkill, New York

B.A. in Mathematics, 1956, Northwestern University; M.S. in Mathematics, 1957, University of Illinois. Joined IBM in 1957 as a programmer in the Scientific Computation Department of the Data Systems Division, Poughkeepsie. Transferred in 1961 to the Components Division to do mathematical analysis and programming relating to semiconductor device theory.

R. Srinivasan

Thomas J. Watson Research Center, Yorktown Heights, New York

B.Sc. (honors), 1959; M.S., 1950, Madras University, India; Ph.D., 1956, University of Southern California. Visiting professor at City University of New York, 1963-64, Ohio State University, 1966-67. Joined IBM in 1961 in the field of research chemistry at the Research Center. Guggenheim Fellowship, 1965-66. Member Sigma Psi.

Megumu Yoshimine

Research Division, San Jose, California

B.S. in Physics, University of Illinois, 1955; M.S. in Mathematics, San Jose State College, 1967. Assistant Mathematician, Argonne National Laboratory, 1960-1962. Joined IBM in 1962. Currently on leave at Kyushu University where he is completing the requirements for a Ph.D. in Physics.

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